

Electronic Acknowledgement Receipt

EFS ID:	1412946
Application Number:	10040042
International Application Number:	
Confirmation Number:	1835
Title of Invention:	Method for reduction of photomask defects
First Named Inventor/Applicant Name:	Wei-Yu Su
Customer Number:	8933
Filer:	Richard A. Paikoff/Donna Winkler
Filer Authorized By:	Richard A. Paikoff
Attorney Docket Number:	TS01-132
Receipt Date:	03-JAN-2007
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Application Type:	Utility

Payment information:

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File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1		Amendment.pdf	588907	yes	8

	Multipart Description/PDF files in .zip description		
	Document Description	Start	End
	Amendment After Final	1	1
	Claims	2	6
	Applicant Arguments/Remarks Made in an Amendment	7	8

Warnings:

Information:

Total Files Size (in bytes):	588907
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New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.